


**In the United States Patent and Trademark Office**

Serial No.: 10/550,855 § Filing Date: 18 September 2006
§
Title: FORMATION OF THIN SEMI- § Examiner: MCCALL SHEPARD, Sonya D
CONDUCTOR LAYERS BY LOW- § Conf. No.: 3611
ENERGY PLASMA ENHANCED §
CHEMICAL VAPOR DEPOSITION - §
AND SEMICONDUCTOR §
HETEROSTRUCTURE DEVICES §
§
Applicant: VON KAENEL, Hans § Atty Docket No.: PUS-E005-013

CERTIFICATE OF TRANSMISSION UNDER 37 CFR §1.8. I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office

On 29 January 2010

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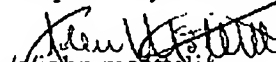
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Dear Sirs:

Attached please find a Fee(s) Transmittal Form for the above-identified application.

Authorization is hereby given to charge the required fees, or credit any overpayment to our deposit account No. 50-2621.

Respectfully submitted,


/s/ John Moeteli

Date: January 28, 2010

John MOETELI
U.S. Reg. No. 35,289

Encl: - Fee(s) Transmittal Form